EAST Search History

EAST Search History (Prior Art)

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L7	1	("5042895").PN.	USPAT; USOCR	OR	OFF	2009/08/12 16:17
L8	5	process controller with discrete$2 with continuous$2	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:45
L9	334	digital with analog with power controller	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:52
L10	151	digital with analog with power controller and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:52
L11	1	discrete$2 with continuous$2 with power controller and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:57
L12	1	discrete$2 with digital with power controller and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:58
L13	769	discrete$2 with digital with controller and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:59
L14	245	discrete$2 with continuous$2 with controller and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:59
L15	32	discrete$2 with continuous$2 with controller with process$3 and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 16:59

L16	1514	pulsed plasma	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 17:48
L17	195	pulsed plasma and PECVD	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 17:49
L18	81	pulsed plasma and PECVD and @PY<"2005"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 17:49
L19	11	pulsed plasma and PECVD and discrete and @PY<"2005"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 17:49
S1	2	"US 20050220984"	US-PGPUB; USPAT; USOCR; DERWENT	ADJ	ON	2009/08/03 14:35
S2	2	"US 20050220984"	US-PGPUB; USPAT; USOCR; DERWENT	ADJ	ON	2009/08/03 14:35
S4	3	(("5643638") or ("5042895") or ("5946542")).PN.	USPAT; USOCR	OR	OFF	2009/08/03 14:47
S5	6	plasma with (vapor deposition or CVD or PVD or PECVD or MOCVD) and (silane or sih4 or "sih.sub.4") and (ellipsomet$3 or reflectomet$3) with "in situ"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/03 15:46
S6	2	"20020126283".pn.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 13:55

S7	74	("20020024668" | "4379040" | "4588942" | "4957605" | "5042951" | "5091320" | "5126028" | "5131652" | "5131752" | "5223356" | "5354575" | "5494697" | "5503707" | "5665214" | "6081334" | "6504608").PN. OR ("5665214" | "5955139" | "6868312").URPN.	US-PGPUB; USPAT; USOCR	ADJ	ON	2009/08/04 13:59
S8	451	(RF or plasma or microwave) with (power or energy) with (refract$4 near4 index)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 14:40
S9	5	S7 and S8	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 14:40
S10	166	(RF or plasma or microwave) with (power or energy) with (refract$4 near4 index) and waveguide	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 15:44
S11	73	(RF or plasma or microwave) with (power or energy) with (refract$4 near4 index) and waveguide and wafer	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 15:44

S12	60	("20020055801" | "20020075488" | "20020083401" | "20030113085" | "20060258062" | "5042895" | "5271264" | "5467883" | "5479340" | "5578161" | "5643638" | "5653894" | "5654903" | "5737496" | "5807761" | "5821502" | "5846373" | "5910011" | "5946542" | "0522023" | "6051284" | "6052183" | "6068783" | "6146492" | "6160621" | "6326794" | "6348419" | "6353210" | "6413867" | "6633831" | "7092602").PN.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 15:46
S13	41	(RF or plasma or microwave) with (power or energy) with (refract$4 near4 index) and waveguide and silane	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 15:48
S14	28	(RF or plasma or microwave) with (power or energy) with (refract$4 near4 index) and waveguide with silicon and micron	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:24
S15	2750	waveguide with silicon and micron	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:25

S16	853	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and micron	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:25
S17	316	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and PECVD	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:26
S18	89	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and PECVD and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:26
S19	57	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and PECVD and silane and @PY<"2006"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:27
S20	86	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and PECVD and refraction and @PY<"2006"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:28
S21	40	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) and PECVD and refraction and silane and @PY<"2006"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:28
S22	3	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) with ".mu.m" and PECVD and refraction and silane and @PY<"2006"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:32
S23	17	waveguide with (silane or silicon) with (oxide or nitride or oxynitride) with ".mu.m" and silane and @PY<"2006"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/04 16:32

S24	378	("siH.sub.4" or sih4 or silane or disilane or si2h4 or "si.sub.2" "h.sub.4") with (n2o or "n.sub.2" O or nitrous oxide) and refractive index and (PECVD or plasma enhanced (CVD or chemical vapor deposition))	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 13:37
S25	259	("siH.sub.4" or sih4 or silane or disilane or si2h4 or "si.sub.2" "h.sub.4") with (n2o or "n.sub.2" O or nitrous oxide) and refractive index and (PECVD or plasma enhanced (CVD or chemical vapor deposition)) and @PY<"2005"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 13:37
S26	62	("siH.sub.4" or sih4 or silane or disilane or si2h4 or "si.sub.2" "h.sub.4") with (n2o or "n.sub.2" O or nitrous oxide) and refractive index and waveguide and (PECVD or plasma enhanced (CVD or chemical vapor deposition)) and @PY<"2005"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 13:37
S27	29	process with controller with continuous with discrete	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:50
S28	1	process with controller with continuous with discrete and deposition	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:51
S29	2	(process with controller with continuous with discrete).ab.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:51

S30	260	(process with controller with continuous).ab.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:55
S31	6	(process with controller with continuous).ab. and deposition	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:55
S32	171	(process with controller with continuous).ab. and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:56
S33	29	(process with controller with continuous with discrete)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 17:56
S34	44	(process with controller with discrete).ab.	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/05 18:07
S35	4	discrete control process	US-PGPUB; USPAT; USOCR; DERWENT	ADJ	ON	2009/08/12 11:55
S36	14	(process with controller with discrete).ab. and power	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 11:55
S37	32	(process with controller with discrete with power)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 11:58
S38	2	process near5 controller near5 discrete near20 power	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 12:00
S39	121	process near5 controller near5 discrete	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 12:00

S40	84	process near5 controller near5 discrete and @PY<"2004"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2009/08/12 12:00
S41	1	process near5 controller near5 discrete and @PY<"2004"	USOCR	ADJ	ON	2009/08/12 12:08
S42	29	118/688.ccls.	USOCR	ADJ	ON	2009/08/12 12:56
S43	2	118/688.ccls. and discrete	USOCR	ADJ	ON	2009/08/12 12:56
S44	2	"US 20050220984"	US-PGPUB; USPAT; USOCR; DERWENT	ADJ	ON	2009/08/12 12:58
S45	1	discrete with power stepping	USOCR	ADJ	ON	2009/08/12 12:59

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